	Application No.	Applicant(s)
Notice of Allowability	10/814,375	DUBIN, VALERY M.
	Examiner	Art Unit
	Nitin Parekh	2811
The MAILING DATE of this communication appears All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate comming IGHTS. This application is:	n this application. If not included unication will be mailed in due course. THIS
1. This communication is responsive to <u>5-31-07</u> .		
2. The allowed claim(s) is/are <u>2-4,10,11,17-19 and 31-39</u> .		
3. Acknowledgment is made of a claim for foreign priority ur	nder 35 U.S.C. § 119(a)-(d)	or (f).
a) ☐ All b) ☐ Some* c) ☐ None of the:		
 Certified copies of the priority documents have 	e been received.	,
Certified copies of the priority documents have	been received in Application	on No
Copies of the certified copies of the priority do	cuments have been receive	d in this national stage application from the
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	MENT of this application.	
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EX es reason(s) why the oath o	AMINER'S AMENDMENT or NOTICE OF r declaration is deficient.
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.	
(a) ☐ including changes required by the Notice of Draftspers	on's Patent Drawing Review	w (PTO-948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment o	r in the Office action of
Identifying indicia such as the application number (see 37 CFR 1, each sheet. Replacement sheet(s) should be labeled as such in the	.84(c)) should be written on t he header according to 37 CF	he drawings in the front (not the back) of FR 1.121(d).
 DEPOSIT OF and/or INFORMATION about the depo- attached Examiner's comment regarding REQUIREMENT 	SIT OF BIOLOGICAL MATE FOR THE DEPOSIT OF BIO	ERIAL must be submitted. Note the DLOGICAL MATERIAL.
Attachment(s) 1. ☑ Notice of References Cited (PTO-892)	5 🗀 Notice of In	formal Patent Application
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)		ummary (PTO-413),
	Paper No.	/Mail Date
Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date	7. ⊠ Examiner's	Amendment/Comment
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛭 Examiner's	Statement of Reasons for Allowance
	9.	Nitin Parekh Primary Examiner Tech Center 2800

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DETAILED ACTION

Allowable Subject Matter

- 1. Claims 2-4, 10, 11, 17-19 and 31-39 are allowed.
- 2. Claims 40-42 have been canceled.

Examiner's Amendment

- 3. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.
- A. Cancel claims 40-42.
- B. At the end of the last line 5, claim 17: Insert "onto the substrate at a rotation speed of between about 20 and about 100 rpm for a time of between about 1 and about 5 minutes and annealing the substrate at a temperature of between about 200 and about 500 °C for a time of between about 1 and about 200 minutes.
- C. Claim 31, line 7: Delete "a" and insert ---- "the" ---.

Authorization for this examiner's amendment was given in a telephone interview with Angela Sagalewicz on 8-6-07.

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Reasons for Allowance

4. The following is an examiner's statement of reasons for allowance:

The references of record do not teach the limitations "forming or providing a solution containing metal ions and carbon nanotubes, and co-depositing the metal ions and the carbon nanotubes onto a substrate utilizing the solution to form a metal layer" and "said co-depositing including spin coating onto the substrate at a rotation speed of between about 20 and about 100 rpm for a time of between about 1 and about 5 minutes and annealing the substrate at a temperature of between about 200 and about 500 °C for a time of between about 1 and about 200 minutes" in a method of fabricating an IC having a conductive layer including carbon nanotubes.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nitin Parekh whose telephone number is 571-272-1663. The examiner can normally be reached on 09:00AM-05:30PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Lynne Gurley can be reached on 571-272-1670. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAN or Public PAG. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAG system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

NP

8-08-07

NITIN PAREKH

PRIMARY EXAMINER

TECHNOLOGY CENTER 2800